Icemos Technology Ltd Product Specification 1000.679001 Issue Date 18 February 2021 17::

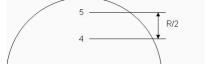
Part Number Customer
----------------------

Category	Parameter		Specification	Measurement Method
OverallWafer	1.0	Diameter	200.00 +/- 0.50 mm	
	2.0	Notch or Flat	Notch	Wafer Vendor
	3.0	Notch Direction	<110> +/- 1 degree	Wafer Vendor
	4.0	Overall Thickness	566.00 +/- 26.10 μm	ADE, 100%
	5.0	Total Thickness Variation (TTV)	<5.00μm	Guaranteed by Process
	6.0	Bow	<80.00μm	ADE to ASTM F534, 20%
	7.0	Warp	<80.00μm	ADE to ASTM F657, 20%
	8.0	Edge Chips	0	Bright Light, 100% (note 2)
	9.0	Edge Exclusion	5mm	
HandleSilicon	10.0	Handle Growth Method	CZ	Wafer Vendor
	11.0	Handle Orientation	{100} +/- 1 degree	Wafer Vendor
	12.0	Handle Thickness	550.00 +/- 25.00 μm	ADE, 100%
	13.0	Handle Doping Type	P	Wafer Vendor
	14.0	Handle Dopant	Boron	Wafer Vendor
	15.0	Handle Resistivity	>0.001 Ohmcm	Wafer Vendor
	16.0	Backside Finish	Polished with oxide	
BuriedOxide	17.0	Oxide Type	Thermal	
	18.0	Oxide Thickness	10,000.00 +/- 500.00 A	Nanospec centre point, 4%
	19.0	Oxide formed on	Handle Wafer	
DeviceSilicon	20.0	Device Growth Method	CZ	Wafer Vendor
	21.0	Device Orientation	{100} +/- 1 degree	Wafer Vendor
	22.0	Nominal Thickness	15.00 +/- 1.00 μm	ADE single point - 100%
	23.0	Distance to device silicon edge from wafer edge	<= 2 mm	Typical by Process
	24.0	Edge Removal Depth in Handle	<100um	Graranteed by process
	25.0	Device Doping Type	P	Wafer Vendor
	26.0	Device Dopant	Boron	Wafer Vendor
	27.0	Device Resistivity	0.001 ~ 0.005 Ohm-cm	Wafer Vendor
	28.0	Voids	0	Bright Light, 100% (note 2)
	29.0	Scratches	none	Bright Light, 100% (note 2)
	30.0	Haze	none	Bright Light, 100% (note 2)

Page 1 of 2 26/10/2021 www.icemostech.com

reemos reemology Ltu		Todact Specification	1000.077001	issuc Date	Date 101 columny 2021 17	
Part Number		Customer				
Category	Parameter	Specification		Me	asurement Method	
Shipping Details	Wafer per box :	Max 25				
	Packaging:	Taped Polypropylene Wafer Bo Empak, Ultrapak, 200.00mm Antistatic Double Bagging	)X			
	Lot Shipment Data	Device Thickness Bow / Warp Data Handle and SOI Thickness				
Explanatory Notes	1. Microscope inspec	ction performed using microscope so	can as below. 5x objec	tive.		
	2. All bright light ins	pections performed exclude all wafe	er area outside the edg	e exclusion define	d in Overall	

Wafer, Edge Exclusion. High intensity bright lamp inspection as per ASTM F523.



3. 9 point measurement are as shown in the diagram below:

10mm

Additional Information